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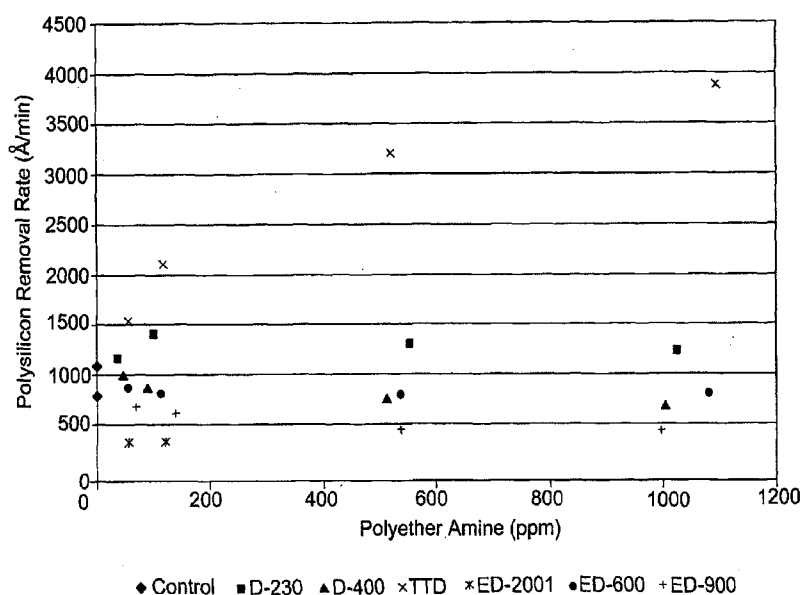
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[Continued on next page]

(54) Title: POLISHING COMPOSITION CONTAINING POLYETHER AMINE



(57) Abstract: The inventive chemical-mechanical polishing system comprises a polishing component, a liquid carrier, and a polyether amine. The inventive method comprises chemically-mechanically polishing a substrate with the aforementioned polishing system.



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- *as to the applicant's entitlement to claim the priority of the earlier application (Rule 4.17(iii))*

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